

Abstract Submitted
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Sb_xO_y thin films using pulsed lased deposition¹ JAMES HAGGERTY, BETHANY MATHEWS, JANET TATE, Oregon State University, VLADAN STEVONOVIC COLLABORATION², STAPHAN LANY COLLABORATION³ — We demonstrate synthesis of Sb₂O₃ and Sb₂O₄ thin films on heated glass, and fused SiO₂ slides in an oxygen atmosphere using pulsed laser deposition and ex-situ annealing in air. GW calculations with spin-orbit corrections predict that the band gap of Sb₂O₃ changes from 3.4 eV in the orthorhombic β -phase to 4.7 eV in the cubic α -phase. Sb₂O₄ also forms two polymorphic structures, orthorhombic α -Sb₂O₄, and monoclinic β -Sb₂O₄. Optical absorption and crystal structure are investigated using transmission/reflection spectroscopy and grazing incidence x-ray diffraction. Optical absorption measurements of α -Sb₂O₄ show a band gap of 3.9 eV which is far from the DFT predicted band gap of 2.1 eV but agrees with previous measurements. Structural analysis shows that from an α -Sb₂O₄ target, α -Sb₂O₄ thin films are formed at a temperature and pressure of 400 °C and 3 mTorr. Deposition at higher pressures (6 and 12 mTorr) produces amorphous films that, when annealed at 500 °C become a mixture of α -Sb₂O₄ and an additional cubic phase of Sb₂O₄.

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